

#### 5.4.4. Base spreading resistance and emitter current crowding

Large area bipolar transistors can have a very non-uniform current distribution due to the resistance of the base layer. Since the base current is applied through the thin base layer, there can be a significant series resistance in large devices. This resistance causes a voltage variation across the base region. This voltage variation in turn causes a variation of the emitter current density, especially since the emitter current density depends exponentially on the local base-emitter voltage. This effect is minimal in the center of the emitter-base diode and strongly increases toward the edges. In extreme cases, this effect causes the emitter current to occur only at the very edges of the emitter-base diode. The parameters involved include the sheet resistance of the base layer, the emitter current density and the current gain in the device. The characteristic length,  $I_{spreading}$ , can be obtained from a distributed model similar to that of a metal contact to a thin semiconductor layer as described in Section 3.9.

$$I_{spreading} = \sqrt{\frac{r_E Area}{R_{s,B}}} = \sqrt{\frac{V_t}{J_E R_{s,B}}} \quad (5.4.11)$$

Where  $r_E$  is the small signal emitter resistance,  $R_{s,B}$  is the sheet resistance of the base and  $J_E$  is the emitter current density. This analysis is only valid if the emitter current density is close to uniform. The emitter current density in a BJT can only be considered close to uniform if the emitter stripe width is less than the characteristic length in the case of a one-sided base contact or less than twice the characteristic length in the case of a double sided base contact or:

$$W_{s,E} \leq 2I_{spreading} \quad (5.4.12)$$

The corresponding value of the base resistance for a uniform emitter current distribution equals:

$$R_B = \frac{1}{3} R_s \frac{W_{s,E}}{L_{s,E}} \quad (5.4.13)$$

for a one-sided base contact and

$$R_B = \frac{1}{12} R_s \frac{W_{s,E}}{L_{s,E}} \quad (5.4.14)$$

for a double-sided base contact, which effectively has the resistance of two sections with half the emitter stripe width connected in parallel. A series of narrow emitter fingers with alternating base contacts is therefore typically used in large area power device, resulting in the characteristic interdigitated structure.